**PATENT** 1201.63407 IN THE UNITED STATES PATENT AND TRADEMARK OFFICE Nayfeh et al. Applicant: I hereby certify that this paper is being deposited with 09/496,506 Serial No.: the United States Postal Service as first-class mail in an envelope addressed to: Assistant Commissioner for Patents, Washington, D.C. 20231, on this date. Filed: February 2, 2000 19/00 Date SILICON NANOPARTICLE FIELD For: Registration No. F-CLASS.WCM EFFECT TRANSISTOR AND Attorney for Applican TRANSISTOR MEMORY DEVICE

## PRELIMINARY AMENDMENT

Assistant Commissioner for Patents Washington, D.C. 20231

Dear Sir:

Group Art Unit:

Prior to examination of this application, please amend the application as

follows:

M

## **IN THE SPECIFICATION:**

Please amend the specification as follows:

Page 9, line 12, delete "particles of 1 nm across contain less than one in a

million holes," and insert /-less than one in one million particles may contain a hole, /- .